

GaP - Gallium Phosphide

Electrical properties

Basic Parameters

[Mobility and Hall Effect Transport Properties in High Electric Fields](#)

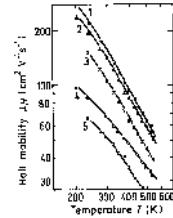
[Impact Ionization](#)

[Recombination Parameters](#)

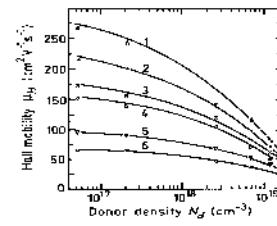
Basic Parameters

Breakdown field	$\approx 1 \cdot 10^6$ V/cm
Mobility electrons	≤ 250 cm ² V ⁻¹ s ⁻¹
Mobility holes	≤ 150 cm ² V ⁻¹ s ⁻¹
Diffusion coefficient electrons	≤ 6.5 cm ² /s
Diffusion coefficient holes	≤ 4 cm ² /s
Electron thermal velocity	$2 \cdot 10^5$ m/s
Hole thermal velocity	$1.3 \cdot 10^5$ m/s

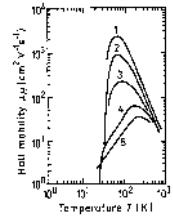
Mobility and Hall Effect



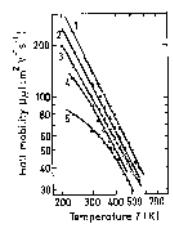
Electron Hall mobility versus temperature for different donor (Sn) densities.
 N_d (cm⁻³): 1. $5 \cdot 10^{16}$; 2. $2 \cdot 10^{17}$; 3. $2.5 \cdot 10^{18}$; 4. $7.5 \cdot 10^{18}$; 5. $1.2 \cdot 10^{19}$.
[\(Kao and Eknayan \[1983\]\).](#)



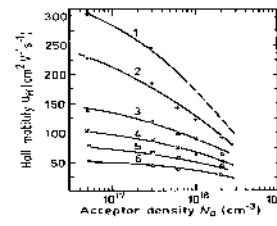
Electron Hall mobility versus donor (Sn) density at different temperature.
 T (K): 1. 203; 2. 233; 3. 273; 4. 300; 5. 400; 6. 500.
For $T > 200$ K electron Hall mobility $\mu_{nH} \sim T^{-1.7}$.
[\(Kao and Eknayan \[1983\]\).](#)



Electron Hall mobility versus temperature for different acceptor (Zn) densities.
 N_a (cm⁻³): 1. $6.7 \cdot 10^{16}$; 2. $1.9 \cdot 10^{17}$; 3. $6.7 \cdot 10^{17}$; 4. $3.8 \cdot 10^{18}$; 5. $1.2 \cdot 10^{19}$.
[\(Casey et al. \[1969\]\).](#)

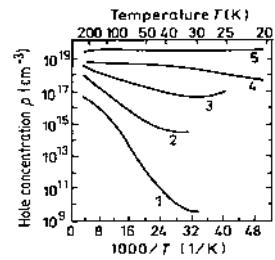


Hole Hall mobility versus temperature for different acceptor (Mg) densities.
 N_a (cm⁻³): 1. $5 \cdot 10^{16}$; 2. $3 \cdot 10^{17}$; 3. $6 \cdot 10^{17}$; 4. $1 \cdot 10^{18}$; 5. $2 \cdot 10^{18}$.
[\(Kao and Eknayan \[1983\]\).](#)



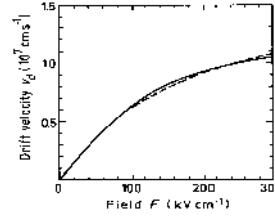
Hole Hall mobility versus acceptor (Mg) density at different temperature.
 T (K): 1. 203; 2. 233; 3. 300; 4. 350; 5. 400; 6. 500.
For $T > 200$ K hole Hall mobility $\mu_{pH} \sim T^{-2.3}$.
[\(Kao and Eknayan \[1983\]\).](#)

Electrical properties of Gallium Phosphide (GaP)



Hole concentration versus temperature for different acceptor (Zn) densities.
 $N_a \text{ (cm}^{-3}\text{): 1. } 6.7 \cdot 10^{16}; 2. } 6.7 \cdot 10^{17}; 3. } 3.8 \cdot 10^{18}; 4. } 1.2 \cdot 10^{19}; 5. } 2.1 \cdot 10^{19}$.
[\(Casey et al. \[1969\]\)](#).

Transport Properties in High Electric Fields

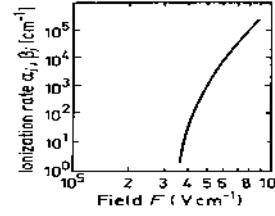


Field dependences of the electron drift velocity 300 K.
Solid line shows the result of the calculation.
Dashed line shows the experimental results
[\(Arora et al. \[1987\]\)](#).

Saturation electron drift velocity

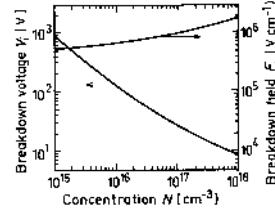
$v_s = 1.25 \cdot 10^7 \text{ cm/s}$ (300 K)
[\(Johnson and Eknayan \[1985\]\)](#)

Impact Ionization



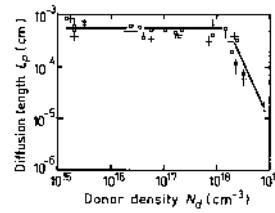
The dependence of ionization rates for electrons α_i and holes β_i versus electric field, 300 K.
 $\alpha_i = \beta_i$
[\(Sze \[1969\]\)](#).

At 300 K for $5 \cdot 10^5 \text{ V/cm} < F < 1.3 \cdot 10^6 \text{ V/cm}$
 $\alpha_i = \beta_i = \alpha_0 \cdot \exp(\delta - (\delta^2 + (F_0/F)^2)^{1/2})$,
where $\alpha_0 = 0.39 \cdot 10^6 \text{ cm}^{-1}$, $\delta = 19.1$, $F_0 = 7.51 \cdot 10^6 \text{ V cm}^{-1}$
[\(Kyuregyan and Yurkov \[1989\]\)](#).

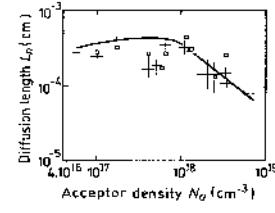


Breakdown voltage and breakdown field versus doping density for an abrupt p-n junction, 300 K
[\(Sze and Fibbons \[1966\]\)](#).

Recombination Parameters



Hole diffusion length L_p in n-type GaP (undoped or doped with S) versus donor density, 300 K
[\(Young and Wight \[1974\]\)](#).



Electron diffusion length L_n in p-type GaP versus acceptor (Zn) density, 300 K
[\(Young and Wight \[1974\]\)](#).

The longest lifetime of holes (undoped GaP)

$$\tau_p \sim 1 \cdot 10^{-6} \text{ s}$$

Electrical properties of Gallium Phosphide (GaP)

$$\text{Diffusion length } L_p = (D_p \cdot \tau_p)^{1/2}$$

$$L_p \sim 20 \mu\text{m.}$$

The longest lifetime of electrons

$$\tau_n \sim 1 \cdot 10^{-7} \text{ s}$$

$$\text{Diffusion length } L_n = (D_n \cdot \tau_n)^{1/2}$$

$$L_n \sim 7 \mu\text{m}$$

Surface recombination

(Gershenson and Mikulyak [1966])

20 K	$(0.1 \div 3.4) \cdot 10^2 \text{ cm/s}$
77 K	$(1.1 \div 90) \cdot 10^4 \text{ cm/s}$
300 K	$(0.4 \div 2) \cdot 10^6 \text{ cm/s}$

Radiative recombination

Band to band radiative recombination coefficient

$$\sim 10^{-13} \text{ cm}^3/\text{s}$$

Impurity recombination at 300 K

(Yunovich [1972], Bergh and Dean [1976])

Zn-O complex (red LED, $h\nu \approx 1.8 \text{ eV}$, $\lambda \approx 0.7 \mu\text{m}$)

Radiative exciton lifetime	$\sim 10^{-7} \text{ s}^{-1}$
Oscillator force for exciton recombination	0.07
Non - radiative exciton lifetime:	$B \approx 10^{-10} \div 10^{-11} \text{ cm}^3/\text{s}$
$\tau_{xn} = 1/B \cdot p$	

$$\text{Non - radiative single electron lifetime: } \tau_{cn} = 1/C \cdot p^2$$

N - isoelectron impurity (green LED, $h\nu \sim 2.22 \text{ eV}$, $\lambda \sim 0.56 \mu\text{m}$)

Radiative exciton lifetime	$\sim 3 \cdot 10^{-8} \text{ s}$
Oscillator force for exciton recombination	0.09
Bond energy of exciton in GaP doped with N: free exciton	0.021 eV
NN bound exciton	0.143 eV

Auger recombination coefficient

$$\sim 10^{-30} \text{ cm}^6/\text{s}$$

